Amendments to the claims:

Cancel claims 1, 2, 3, 4, 5, 15 and 25.

Claims 6, 16 and 16 are amended.

New claims 44-52 are added.

1.-5. (Cancelled)

1	6. (Currently Amended) A spin valve transistor as claimed in claim 4 wherein A spin
2	valve transistor comprising:
3	an emitter;
4	a collector;
5	a base between the emitter and the collector;
6	a spin valve including:
7	a ferromagnetic free layer structure;
8	a self-pinned antiparallel (AP) pinned layer structure without any pinning structure
9	pinning the self-pinned AP pinned layer structure; and
10	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
11	structure; and
12	the base comprising at least said free layer structure;
13	the self pinned AP pinned layer structure comprising:
14	a ferromagnetic first antiparallel (AP) pinned layer;
15	a ferromagnetic second antiparallel (AP) pinned layer;
16	a nonmagnetic antiparallel coupling (APC) layer located between the first and
17	second AP pinned layers;
18	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with
19	a positive magnetostriction;
20	the CoFe film having a magnetostrictive anisotropy field that is oriented
21	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
22	layer structure; and
23	the first and second AP pinned layers [[have]] having the same magnetic thickness.

1	7. (Fleviously Flesented) A spin valve transistor comprising.		
2	an emitter;		
3	a collector;		
4	a base between the emitter and the collector;		
5 .	a spin valve including:		
6	a ferromagnetic free layer structure composed of iron (Fe);		
7	a self-pinned antiparallel (AP) pinned layer structure;		
8	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer		
9	structure; and		
10	the free layer structure interfacing the spacer layer;		
l 1	the base comprising at least said free layer structure;		
12	the self pinned AP pinned layer structure including:		
13	a ferromagnetic first antiparallel (AP) pinned layer;		
14	a ferromagnetic second antiparallel (AP) pinned layer; and		
15	a nonmagnetic antiparallel coupling (APC) layer located between the first and		
16	second AP pinned layers;		
17	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;		
18	the second AP pinned layer including:		
19	an iron (Fe) film;		
20	a cobalt iron (CoFe) film with a positive magnetostriction;		
21	the iron (Fe) film being located between and interfacing the APC layer and the		
22	cobalt iron (CoFe) film; and		
23	the CoFe film having a magnetostrictive anisotropy field that is oriented		
24	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinne		
25	layer structure.		
1	8. (Original) A spin valve transistor as claimed in claim 7 wherein the cobalt iron		
2	is $Co_{90-50}Fe_{10-50}$.		
	v		

I	9.	(Previously Presented) A spin valve transistor as claimed in claim 7 wherein the	
2	cobalt iron (C	oFe) film is Co ₅₀ Fe ₅₀ .	
1	10.	(Original) A spin valve transistor as claimed in claim 9 wherein the first and	
2	second AP pi	nned layers have the same magnetic thickness.	
1	11.	(Withdrawn) A spin valve transistor as claimed in claim 4 further comprising:	
2	the se	cond AP pinned layer being composed of iron (Fe);	
3	the fir	st AP pinned layer including:	
4		first and second iron (Fe) films with the first iron (Fe) film interfacing the spacer	
5	layer;		
6		said cobalt iron (CoFe) film; and	
7		the cobalt iron (CoFe) film being located between and interfacing the first and	
8	secon	l iron (Fe) films.	
1	12.	(Withdrawn) A spin valve transistor as claimed in claim 11 wherein the cobalt	
2	iron film is C	$^{1}_{90-50}$ Fe $_{10-50}$.	
1	13.	(Withdrawn) A spin valve transistor as claimed in claim 12 wherein the cobalt	
2	iron film is C	$e_{50}Fe_{50}$.	
1	14.	(Withdrawn) A spin valve transistor as claimed in claim 13 wherein the first and	
2	second AP pi	nned layers have the same magnetic thickness.	
	15.	(Cancelled)	
1	16.	(Currently Amended) A magnetic head assembly as claimed in claim 15 wherein	
2	A magnetic h	ead assembly comprising:	
3	a write head;		
4	a read head adjacent the write head;		
5	the re	nd head including:	
6		ferromagnetic first and second shield layers; and	
7		a spin valve transistor located between the first and second shield lavers	

8	the spin valve transistor comprising:		
9	an emitter;		
10	a collector;		
11	a base between the emitter and the collector;		
12	a spin valve including:		
13	a ferromagnetic free layer structure;		
14	a self-pinned antiparallel (AP) pinned layer structure without any pinning		
15	structure pinning the self-pinned AP pinned layer structure;		
16	a nonmagnetic spacer layer between the free layer structure and the AP		
17	pinned layer structure; and		
18	the base comprising at least said free layer structure;		
19	the self pinned AP pinned layer structure comprises: comprising:		
20	a ferromagnetic first antiparallel (AP) pinned layer;		
21	a ferromagnetic second antiparallel (AP) pinned layer;		
22	a nonmagnetic antiparallel coupling (APC) layer located between the first and		
23	second AP pinned layers;		
24	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with		
25	a positive magnetostriction, [[and]]		
26	the CoFe film having a magnetostrictive anisotropy field that is oriented		
27	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned		
28	layer structure[[.]]; and		
29	the first and second AP pinned layers having the same magnetic thickness.		
1	17. (Previously Presented) A magnetic head assembly comprising:		
2	a write head;		
3	a read head adjacent the write head;		
4	the read head including:		
5	ferromagnetic first and second shield layers; and		
6	a spin valve transistor located between the first and second shield layers;		
7	the spin valve transistor comprising:		
8	an emitter;		
9	a collector;		
10	a base between the emitter and the collector;		

11	a spin valve including:		
12	a ferromagnetic free layer structure composed of iron (Fe);		
13	a self-pinned antiparallel (AP) pinned layer structure;		
14	a nonmagnetic spacer layer between the free layer structure and the AP		
15	pinned layer structure; and		
16	the free layer structure interfacing the spacer layer;		
17	the base comprising at least said free layer structure;		
18	the self pinned AP pinned layer structure including:		
19	a ferromagnetic first antiparallel (AP) pinned layer;		
20	a ferromagnetic second antiparallel (AP) pinned layer; and		
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and		
22	second AP pinned layers;		
23	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;		
24	the second AP pinned layer including:		
25	an iron (Fe) film;		
26	a cobalt iron (CoFe) film with a positive magnetostriction;		
27	the iron (Fe) film being located between and interfacing the APC layer and th		
28	cobalt iron (CoFe) film; and		
29	the CoFe film having a magnetostrictive anisotropy field that is oriented		
30	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinner		
31	layer structure.		
1	18. (Previously Presented) A magnetic head assembly as claimed in claim 17 wherein		
2	the cobalt iron is $Co_{90-50}Fe_{10-50}$.		
1	19. (Previously Presented) A magnetic head assembly as claimed in claim 17 wherein		
2	the cobalt iron is Co ₅₀ Fe ₅₀ .		
1	20. (Original) A magnetic head assembly as claimed in claim 19 wherein the first		
2	and second AP pinned layers have the same magnetic thickness.		

1	21.	(Withdrawn)	A magnetic head assembly as claimed in claim 16 further
2	comprising:		
3	the se	cond AP pinned la	ayer being composed of iron (Fe);
4	the fir	st AP pinned layer	r including:
5		first and second	l iron (Fe) films with the first iron (Fe) film interfacing the spacer
6	layer;		
7		said cobalt iron	(CoFe) film; and
8		the cobalt iron	(CoFe) film being located between and interfacing the first and
9	secon	d iron (Fe) film.	
1	22.	(Withdrawn)	A magnetic head assembly as claimed in claim 21 wherein the
2	cobalt iron fil	m is $Co_{90-50}Fe_{10-50}$.	
1	23.	(Withdrawn)	A magnetic head assembly as claimed in claim 22 wherein the cobalt
2	iron film is C	o ₅₀ Fe ₅₀ .	
1	24.	(Withdrawn)	A magnetic head assembly as claimed in claim 23 wherein the first
2	and second A	AP pinned layers ha	ave the same magnetic thickness.
	25.	(Cancelled)	
1	26.	(Currently Am	nended) A magnetic disk drive as claimed in claim 25 wherein A
2	magnetic disl	c drive comprising	<u>r.</u>
3	at lea	st one magnetic he	ead assembly that has a head surface;
4	the m	agnetic head asser	mbly having a write head and a read head;
5	the re	ad head including	<u>.</u>
6		ferromagnetic fi	irst and second shield layers, and
7		a spin valve trar	nsistor located between the first and second shield layers:
8	the sr	oin valve transistor	r comprising:
9	an en	nitter;	
10	a coll	ector;	
11	<u>a</u> base	e between the emi	tter and the collector;

12	a spin valve including:
13	a ferromagnetic free layer structure;
14	a self-pinned antiparallel (AP) pinned layer structure without any pinning structure
15	pinning the self-pinned AP pinned layer structure;
16	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
17	structure; and
18	the base comprising at least said free layer structure;
19	the self pinned AP pinned layer structure comprises: comprising:
20	a ferromagnetic first antiparallel (AP) pinned layer,
21	a ferromagnetic second antiparallel (AP) pinned layer;
22	a nonmagnetic antiparallel coupling (APC) layer located between the first and
23	second AP pinned layers;
24	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with
25	a positive magnetostriction; [[and]]
26	the CoFe film having a magnetostrictive anisotropy field that is oriented
27	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
28	layer structure[[.]]; and
29	the first and second AP pinned layers having the same magnetic thickness;
30	a housing:
31	a magnetic medium supported in the housing;
32	a support mounted in the housing for supporting the magnetic head assembly with said head
33	surface facing the magnetic medium so that the magnetic head assembly is in a transducing
34	relationship with the magnetic medium;
35	a motor for moving the magnetic medium; and
36	a processor connected to the magnetic head assembly and to the motor for exchanging
37	signals with the magnetic head assembly and for controlling movement of the magnetic medium.
1	27. (Previously Presented) A magnetic disk drive comprising:
2	at least one magnetic head assembly that has a head surface;
3	the magnetic head assembly having a write head and a read head;
4	the read head including:
5	ferromagnetic first and second shield layers; and
6	a spin valve transistor located between the first and second shield layers;

7	the spin valve transistor comprising:
8	an emitter;
9	a collector;
10	a base between the emitter and the collector;
11	a spin valve including:
12	a ferromagnetic free layer structure composed of iron (Fe);
13	a self-pinned antiparallel (AP) pinned layer structure;
14	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
15	structure; and
16	the free layer structure interfacing the spacer layer;
17	the base comprising at least said free layer structure;
18	the self pinned AP pinned layer structure including:
19	a ferromagnetic first antiparallel (AP) pinned layer;
20	a ferromagnetic second antiparallel (AP) pinned layer, and
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and
22	second AP pinned layers;
23	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;
24	the second AP pinned layer including:
25	an iron (Fe) film with a positive magnetostriction;
26	a cobalt iron (CoFe) film;
27	the iron (Fe) film being located between and interfacing the APC layer and the
28	cobalt iron (CoFe) film; and
29	the CoFe film having a magnetostrictive anisotropy field that is oriented
30	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
31	layer structure;
32	a housing;
33	a magnetic medium supported in the housing;
34	a support mounted in the housing for supporting the magnetic head assembly with said head
35	surface facing the magnetic medium so that the magnetic head assembly is in a transducing
36	relationship with the magnetic medium;
37	a motor for moving the magnetic medium; and
38	a processor connected to the magnetic head assembly and to the motor for exchanging
39	signals with the magnetic head assembly and for controlling movement of the magnetic medium

1	28. (Original) A magnetic disk drive as claimed in claim 27 wherein the cobalt iron			
2	is $Co_{90-50}Fe_{10-50}$.			
1	29. (Previously Presented) A magnetic disk drive as claimed in claim 27 wherein the			
2	cobalt iron is Co ₅₀ Fe ₅₀ .			
1	30. (Original) A magnetic disk drive as claimed in claim 29 wherein the first and			
2	second AP pinned layers have the same magnetic thickness.			
1	31. (Withdrawn) A magnetic disk drive as claimed in claim 26 further comprising			
2	the second AP pinned layer being composed of iron (Fe);			
3	the first AP pinned layer including:			
4	first and second iron (Fe) films with the first iron (Fe) layer film interfacing the			
5	spacer layer;			
6	said cobalt iron (CoFe) film, and			
7	the cobalt iron (CoFe) film being located between and interfacing the first and			
8	second iron (Fe) film.			
1	32. (Withdrawn) A magnetic disk drive as claimed in claim 31 wherein the cobal			
2	iron is $Co_{90-50}Fe_{10-50}$.			
1	33. (Withdrawn) A magnetic disk drive as claimed in claim 32 wherein the coba			
2	iron is $Co_{50}Fe_{50}$.			
1	34. (Withdrawn) A magnetic disk drive as claimed in claim 33 wherein the first an			
2	second AP pinned layers have the same magnetic thickness.			

base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.

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(Previously Presented)

A spin valve transistor as claimed in claim 9 wherein the

36. (Previously Presented) A spin valve transistor as claimed in claim 35 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.

- 37. (Previously Presented) A spin valve transistor as claimed in claim 36 wherein the first and second AP pinned layers have the same magnetic thickness.
- 38. (Previously Presented) A magnetic head assembly as claimed in claim 19 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
- 39. (Previously Presented) A magnetic head assembly as claimed in claim 38 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
- 40. (Previously Presented) A magnetic head assembly as claimed in claim 39 wherein the first and second AP pinned layers have the same magnetic thickness.
- 41. (Previously Presented) A magnetic disk drive as claimed in claim 29 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
- 42. (Previously Presented) A magnetic disk drive as claimed in claim 41 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
- 43. (Previously Presented) A magnetic disk drive as claimed in claim 42 wherein the first and second AP pinned layers have the same magnetic thickness.

- 1 44. (New) A spin valve transistor as claimed in claim 6 wherein at least one of the 2 AP pinned layers is Co₅₀Fe₅₀.
- 45. 1 (New) A spin valve transistor as claimed in claim 44 wherein the base further 2 comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.

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- 46. (New) A spin valve transistor as claimed in claim 45 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
- 1 47. (New) A magnetic head assembly as claimed in claim 16 wherein at least one of 2 the AP pinned layers is Co₅₀Fe₅₀.
 - 48. A magnetic head assembly as claimed in claim 47 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
 - 49. (New) A magnetic head assembly as claimed in claim 48 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
- 50. (New) A magnetic disk drive as claimed in claim 26 wherein at least one of the 2 AP pinned layers is Co₅₀Fe₅₀.
 - 51. (New) A magnetic disk drive as claimed in claim 50 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
 - 52. (New) A magnetic disk drive as claimed in claim 51 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.